men as native donors and the energy for migration of electron trapped in an oxygen vacancy is very small (~0.01 eV), the activation energy in the extrinsic region may be less than that in the intrinsic region. When the formation of interstitial indiums is begun, the extrinsic region may disappear. Then the activation energy in the intrinsic region must have a larger value than that in the extrinsic region. Consequently, the electrical conduction in the intrinsic region contains the formation of new donor level (Iñ,) represented as Eq. (5). In the extrinsic region, it is believed from the viewpoint of the activation energy (0.24 eV) that electron carriers itinerate in the conduction band. Both Zn<sup>18</sup> and Sn-doped In<sub>2</sub>O<sub>3</sub><sup>15,19</sup> show increased conductivity as compared to undoped In<sub>2</sub>O<sub>3</sub>, but Cd-doped In<sub>2</sub>O<sub>3</sub> shows decreased conductivity compared to pure In<sub>2</sub>O<sub>3</sub> as shown in Figure 4. In other words, the Cd-dopant decreases the electrical conductivity. The increase in CdO mol % decreases the electrical conductivity. This result enables us to consider that the incorporated Cd inhibits the ionization of In, to In, and results in the decrease of the concentration of conduction electron and electrical conductivity with increasing CdO mol %.

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#### References

- 1. L. C. Schmacher, S. Mamichi-Afara, and M. J. Dignam, J. Electrochem. Soc., 133, 716 (1986).
- 2. D. Laser, J. Appl. Phys., 52, 5179 (1981).

- 3. K. Otsuka, T. Yasui, and A. Morikawa, Bull. Chem. Soc. Jpn., 55(6), 1768 (1982).
- S. H. Lee, G. Heo, K. H. Kim, and J. S. Choi, *Int. J. Chem. Kinetics*, 19(1), 1 (1987).
- Z. Ovadyahu, B. Ovryn, and H. W. Kraner, J. Electrochem. Soc., 130(4), 917 (1983).
- 6. J. H. W. de Wit, J. Sol. Sta. Chem., 8, 142 (1973).
- 7. J. H. W. de Wit, *ibid.*, **13**, 192 (1975).
- 8. Y. Kanai, Jpn. J. Appl. Phys., 24(5), L361 (1985).
- W. R. Runyan, "Semiconductor Measurements and Instrumentation", McGraw-Hill Co., New York, p.65, 1975.
- J. F. McCan and J. O, M. Bockris, J. Electrochem. Soc., 128, 1719 (1981).
- R. L. Weiher and B. G. Dick, J. Appl. Phys., 35(12), 3511 (1964).
- 12. A. K. Vijh, J. Phys. Chem. Solids, 29, 2233 (1969).
- 13. I. Hamberg and C. G. Granqvist, *J. Appl. Phys.*, **60**(11), R123 (1986).
- 14. J. H. W. de Wit, G. van Unen, and M. Lahey, *J. Phys. Chem. Solids*, **38**, 819 (1977).
- J. L. Bates, C. W. Griffin, D. D. Marchant, and J. E. Granier, Am. Ceram. Soc. Bull., 65(4), 673 (1986).
- A. Gupta, P. Gupta, and V. K. Srivastava, *Thin Solid Films*, 123, 325 (1985).
- C. A. Pan and T. P. Ma, Appl. Phys. Lett., 37(163), 714 (1980).
- 18. R. L. Weiher, J. Appl. Phys., 33(9), 2834 (1962).
- 19. Y. Kanai, Jpn. J. Appl. Phys., 23(1), L12 (1984).
- C. A. Pan and T. P. Ma, J. Electrochem. Soc., 128(9), 1953 (1981).

# Reaction of Triethylsilyl Radical with Sulfides, a Laser Flash Photolysis Study

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Triethylsilyl radical was generated by laser flash photolysis of a 1:1 (v/v) solution of triethylsilane and di-*tert*-butyl peroxide. The silicon centered radical was reacted with sulfides to give carbon centered radicals by displacement at sulfur. The carbon radicals were readily detected by their transient absorption spectra. The absolute rate of reaction of triethylsilyl radical with 9-fluorenylphenylsulfide, di-n-butylsulfide, di-sec-butyl sulfide, di-*tert*-butyl sulfide and di-n-butyl disulfide are  $2.40 \pm 0.12 \times 10^8 \text{ M}^{-1}\text{s}^{-1}$ ,  $11.21 \pm 0.89 \times 10^6 \text{ M}^{-1}\text{s}^{-1}$ ,  $8.79 \pm 0.73 \times 10^6 \text{ M}^{-1}\text{s}^{-1}$ ,  $3.29 \pm 0.18 \times 10^6 \text{ M}^{-1}\text{s}^{-1}$ , and  $3.41 \pm 0.09 \times 10^8 \text{ M}^{-1}\text{s}^{-1}$ , respectively.

# Introduction

Silicon and tin centered radicals rapidly abstract halogen atoms from alkyl halides to generate carbon centered radicals.<sup>2</sup> This approach has been used numerous times to generate organic radicals for study by EPR or laser flash photolysis, or for use in organic synthesis. One of the more common approaches is to photolyze a solution of di-*tert*-butyl peroxide (DTBP) and triethylsilane containing a halogen atom donor RX. Under these conditions R· can be can be

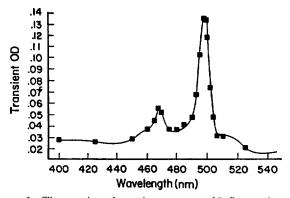


Figure 1. The transient absorption spectrum of 9-fluorenyl produced by laser flash photolysis of 1/1 triethylsilane/DTBP containing 9-fluorenylphenylsulphide.

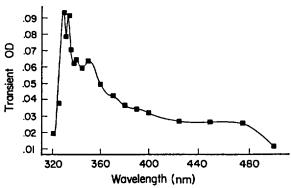


Figure 2. The transient absorption spectrum of benzhydryl produced by laser flash photolysis of 1/1 triethylsilane/DTBP containing 3.

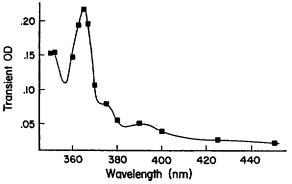


Figure 3. The transient absorption spectrum of 1-naphthylmethyl produced by laser flash photolysis of 1/1 triethylsilane/DTBP containing 4.

generated via reaction<sup>1-3</sup>.

$$(tert-BuO)_{2} \xrightarrow{h\nu} 2 tert-BuO$$
 (1)

$$Et_3Si \cdot +RX \rightarrow Et_3SiX +R \cdot$$
 (3)

In certain cases, halides are inconvenient precursors to free radicals, particularly when RX is too labile to isolate or it reacts on mixing with triethylsilane. Hart has encountered this problem in his sythetic work on free radical cyclizations and found that arvl sulfides are convenient substitutes for

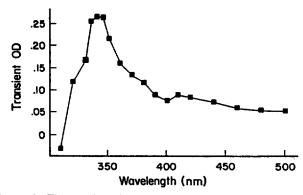


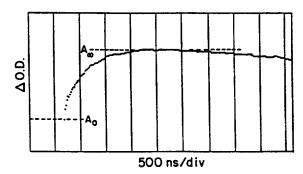
Figure 4. The transient absorption spectrum of anilino radical produced by laser flash photolysis of 1/1 triethylsilane/DTBP containing 5.

RX that are easily prepared and handled.<sup>3</sup> Although there are several absolute rate constants reported for reaction of 1 with halogen donors4 no such data have been reported for sulfides. This has prompted our study of the absolute reactivity of triethylsilyl with various sulfides. This will allow a comparison of the reactivity of triethyl silyl with sulfides and the more traditionally used halide substrates.

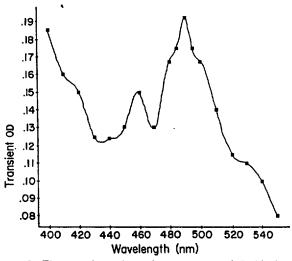
#### Results and Discussion

Laser flash photolysis (337.1 nm) of a solution of 1/1 triethylsilane/DTBP (v/v) containing 9-fluorenylphenylsulfide 2 gives the transient absorption spectrum of Figure 1. This spectrum is identical to that of the 9-fluorenyl radical (FlH·) reported elsewhere. In a similar fashion, flash photolysis of 1/1 triethylsilane/DTBP containing 3, 4, and 5 gives the transient spectra (Figures 2-4) of the benzhydryl radical, 1-naphthylmethyl radical and anilino radical respectively. The spectra are in good agreement with those previously reported for these radicals.6-8

Control experiments with 2-5 in benzene demonstrated that direct laser excitation of these compounds does not produce detectable transient absorbance of the corresponding radicals. The quantum yield for process (4) must be low, but is not necessarily zero. Any radical formed in this reaction would appear "instantaneously" on these time scales and would not inferfere with the kinetic analysis (vide infra).



**Figure 5.** The formation of F1H $\cdot$  following laser flash photolysis of 1/1 triethylsilane/DTBP containing 2.



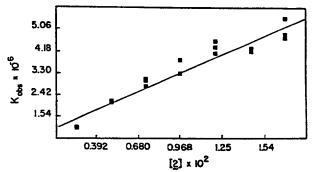
**Figure 6.** The transient absorption spectrum of 9-thiophenyl-fluorenyl radical, obtained by laser flash photolysis of DTBP containing 9-fluorenylphenylsulfide.

The formation of 9-fluorenyl radical is not instantaneous (Figure 5). The formation of F1H follows first order kinetics to give  $k_{obs}$  according to (5)

$$\ln\left(\frac{A_{\infty}}{A_{\infty} - A_{t}}\right) = k_{obs}t\tag{5}$$

where  $A_{\infty}$  is the maximum in the transient absorption of FlH following the laser pulse. The value of  $A_{\infty}$  is taken at the plateau region of Figure 5 prior to the start of FlH decay. Because the pseudo first order rate of formation of FlH is very much faster than its subsequent radical-radical decay, the two processes can be analyzed separately.  $^4A_t$  is the absorption at time = t.

There is no evidence for reaction of *tert* – butoxy radical with **2** as per equation (6) to give **6** under the conditions employed in this work.



**Figure 7.** A plot of  $k_{obs}$  versus concentration of 9-fluorenylphenylsulfide obtained for its reaction with triethylsilyl (see text).

**Table 1.** The Absolute Rate Constants of Reaction of Triethylsilyl Radical with Various Quenchers

Reagent	$\boldsymbol{k_q}(\mathrm{M}^{-1}\mathrm{s}^{-1})$	Ref.
9-bromofluorene	1.27 ± .13×10 <sup>9</sup>	a
9-fluorenylphenylsulfide	$2.40 \pm .12 \times 10^{8}$	а
n - Bu - S - nBu	$11.21 \pm .89 \times 10^{6}$	а
sec-Bu-S-sec-Bu	$8.79 \pm .73 \times 10^{6}$	а
tert-Bu-S-tert-Bu	$3.29 \pm .18 \times 10^{6}$	a
n-Bu-S-S-nBu	$3.41 \pm .09 \times 10^{8}$	а
n-Bu-Br	$5.4 \pm 0.1 \times 10^{8}$	b
tert – Bu–Br	$1.1 \pm 0.5 \times 10^9$	b
n-Bu-Cl	$3.1 \pm 1.4 \times 10^{5}$	b
tert-Bu-Cl	$2.5 \pm 0.2 \times 10^{6}$	b

<sup>&</sup>lt;sup>a</sup>This work, <sup>b</sup>Ref. 4

The spectra of radicals such as 6 are quite different from those of the corresponding hydrocarbon radicals and are quite easy to detect by flash photolysis. 94 We have generated 6 by photolysing solutions of 2 in DTBP alone (Figure 6), and this radical shows a \(\lambda\_{max}\) at 490 nm, which is well separated from the sharp 500 nm maximum found for FlH., but similar to the 490 nm λ<sub>max</sub> reported for 9-chlorofluorenyl radical.9b The complete absence of 6 under our conditions is not surprising. Scaiano has measured the absolute rate constant of reaction (2) to be  $5.7 \pm 0.6 \times 10^6 \text{M}^{-1} \text{s}^{-1}$  at 300K, thus the lifetime of tert - butoxy radical in the presence of 3.13 M triethylsilane (1:1 Et<sub>3</sub>SiH:DTBP) will be less than 56 ns.<sup>4</sup> Thus, even if the absolute rate constant of reaction (6) is as large as 107M-1s-1, then the pseudo first order rate constant for the formation of 6 in a solution containing as much as 0.1M 2 will be 18 times slower than the pseudo first order rate constant of formation of triethylsilyl radical. 10 The observed pseudo first order rate constant for the formation of F1H is related to  $k_a$  the absolute rate of reaction (5) by equation (7),

$$k_{obs} = k_o + k_q$$
 (9-fluorenylphenylsulfide) (7)

where  $k_o$  represents all possible first order decay modes of triethylsilyl radical 1 in the absence of quencher. A plot of  $k_{obs}$  versus [2] from .005-.04M is linear. Two independent determinations of the quenching rate constant gave  $2.40\pm0.12\times10^8\mathrm{M}^{-1}\mathrm{s}^{-1}$  (correlation coefficient = 0.943) and  $2.58\pm0.15\times10^8\mathrm{M}^{-1}\mathrm{s}^{-1}$  (correlation coefficient 0.969) (Figure 7). This rate is about 5 times slower than the rate of reaction of 1 with 9-bromofluorene (Table 1) which we have measured in this work in a manner analogous to that used

with 2.

The reaction of 1 with dialkyl sulfides (reaction 8) gives alkyl radicals which lack a suitable chromophere to allow for their direct detection by laser flash photolysis.

$$Et_3Si + tert-Bu-S-tert-Bu \rightarrow Et_3SiS-tert-Bu+tert-Bu$$
(8)

The kinetics of this process were monitored via a Stern–Volmer approach using 9-fluorenylphenyl sulfide as a kinetic probe. In this experiment the yield of F1H· (formed by flash photolysis of Et<sub>3</sub>SiH/DTBP) containing constant [2], was monitored as a function of added alkyl sulfide or disulfide. Under these conditions equation (9) will hold

$$\frac{\phi^0}{\phi} = 1 + k_q \tau(\mathbf{q}) \tag{9}$$

where  $\phi$  and  $\phi$ ° are the yields of F1H· in the presence and absence of alkyl sulfide respectively,  $k_q$  is the absolute rate constant of reaction (8), [q] is the concentration of alkyl sulfide quencher, and  $\tau$  is the lifetime of formation of triethylsilyl radical in the absence of sulfide quencher. The values of  $\phi$  and  $\phi$ ° are given by  $(A_\infty - A_\phi)$  (see Figure 5). Typical values of  $\tau$  are in the range of 250–300 ns when [2] = 0.02 M. A typical plot of  $\phi$ °/ $\phi$  versus di-n-butyldisulfide is given in Figure 8, and values of  $k_q$  are listed in Table 1. The reactivity trend for triethylsilyl radical is

This trend is opposite to that of organic radical stability (primary<secondary<tertiary). Obviously there is a small steric effect to reaction (8) which offsets the effect of radical stability. The data suggest that the transition structure for reaction (8) is very early, with very little radical development on carbon, hence the small spread (on a factor of 3.4) in the observed rate constants. The absolute reactivity of triethylsilyl radicals with alkylsulfides is comparable to the rate of reaction of 1 with chlorides and much slower than the reaction of 1 with bromides or iodides.

Di-n-butyl disulfide reacts nearly 30 times more rapidly with 1 than do the dialkyl sulfides.

$$Et_3Si + nBu - S - s - n - Bu > Et_3Si - S - n - Bu + n - BuS$$
 (10)

This is not a consequence of the relative bond strengths of C-S and S-S which are nearly identical (65 *versus* 64 Kcal/mol)<sup>11</sup>. The lonyer bond lenyth of S-S relative to C-S (2.05 versus 1.82Å)<sup>11</sup> may lead to increased steric accessibility of the disulfide sulfur, which will accelerate the rate of homolytic displacement.

Chemical analysis of the DTBP, triethylsilane, di-n-butylsulfide system is in agreement with the proposed mechanism. Photolysis of 0.1M dibutylsulfide and 0.1M DTBP in triethylsilane gives a high yield (79%) of silyl sulfide 7 as required by the proposed mechanism. A small quantity of hexaethyldisilane 8 was also formed in the reaction. It was not possible to perform product studies of this type using benzylic sulfides due to the light sensitivity of both the reactants and the expected reaction products.

#### Conclusions

The absolute kinetics of reaction of triethylsilyl radical with various sulfides can be readily monitored by laser flash photolysis. The absolute rate constants for reaction are comparable to the corresponding alkyl chlorides and much slower than the corresponding bromides. This implies that sulfides can be used as convenient precursors for radical generation when the halide is intractable. The kinetics of the reaction are more sensitive to steric effects than to the stability of the radical reaction product which implies a transition state with more sulfur-silicon bond making than carbon-sulfur bond breaking.

#### **Experimental**

Triethyl silane (Aldrich) and DTBP (Mallinkrodt) were used as received. Solutions were placed in 1 cm<sup>2</sup> cylindrical suprasil quartz cells and deoxygenated by bubbling with high purity nitrogen. The samples were irradiated with the pulses of a Molectron UV-22 Nitrogen laser (337.1 nm, 6 mj, 10 ns) which were passed through a beam splitting prism to be coincident with a 1000 Watt xenon arc lamp monitoring beam. In some cases a Lumonics TE-861-4 Excimer laser using a Xe,  $F_2$ , He gas mix (350 mm, -80 mj, 10 ns) was used as the excitation source. Suitable Ealing glass filters were placed between the sample and monochromater photomultiplier tube assembly to prevent laser radiation from impinging on the detector. The monitoring beam was focused on the slit of an Oriel Monochromater with approximately 1 mm front and rear slits. Signals were obtained with an IP 28 photomultiplier tube detector and were digitized by a Tektronix 7912 A/D converter. The experiment was controlled by an Apple He microcomputer which was also used for storage, processing, and hard copies of the data. Absorption spectra were obtained from flowed solutions. Kinetic studies were performed using static samples.

9-Fluorenylphenylsulfide (2), diphenylmethylphenylsulfide (3), 1-naphthyl methylphenylsulfide (4) and N-phenylbenzene-sulfenamide used in this study were prepared and purified by procedures described in the literature. <sup>12-15</sup>

Product analyses were performed by photolyzing degassed solutions sealed in pyrex tubes with a Rayonet Reactor using RPR-350 light sources. The products were analyzed on a Hewlett Packard 5830A G. C. using a 6 ft by 1/8" SE-30 column

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#### References

- 1. Camille and Henry Dreyfus Teacher Scholar
- H. Sakura, Free Radicals Vol. II, J. R. Kochi, ed., Wiley Interscience, New York, NY p. 741 (1973).
- 3. D. J. Hart and Y.-M. Tsai, J. Am. Chem. Soc., 106, 8209 (1984).
- C. Chatgilialoglu, K. U. Ingold, J. C. Scaiano, J. Am. Chem. Soc., 104, 5123 (1982).
- D. Griller, L. Hadel, A. S. Nazran, M. S. Platz, D. C. Wong, T. G. Savino, and J. C. Scaiano, *J. Am. Chem. Soc.*, 106, 2227 (1984).
- 6. A. Porter and E. Strachen, Trans. Far. Soc., 54, 1595

(1985).

- L. M. Hadel, M. S. Platz, and J. C. Scaiano, J. Am. Chem. Soc., 106, 283 (1984).
- 8. Porter, G. Land, Trans. Far. Soc. 59, 2027 (1963).
- 9. (a) Personal communication from D. Griller; (b) D. C. Wong, D. Griller, and J. C. Scaiano, *J. Am. Chem. Soc.* **103**, 5934 (1981).
- Typical rate constants for H atom abstraction reactions of tert Butoxyl with ethers are 10<sup>6</sup>M<sup>-1</sup>s<sup>31</sup> (see V. Malatesta and J. C. Scaiano J. Org. Chem. 47, 1455) (1982). The maximum cocentration of 2 used in these
- experiments was 0.04M thus we feel that 18 represents a conservative lower limit.
- J. E. Huheey, *Inorganic Chemistry*, Harper and Row, New York, N.Y. p. 694-702 (1972).
- L. A. Paquette, W. D. Klobucar, and R. A. Snow, Syn. Comm. 6, 575 (1976).
- G. Farnia, A. Ceccon, and P. Cesseli, J. C. S. Perkin II 1016 (1972).
- 14. P. M. B. Bavin, Can. J. Chem. 38, 917 (1960).
- H. Lecher, K. Koberle, W. Speer, and P. Stocklin, *Ber* 58, 409 (1925).

# Iodine Sorption Complexes of Partially Cobalt(II) Exchanged Zeolite A. Two Crystal Structures of Co<sub>3.5</sub>Na<sub>5</sub>Si<sub>12</sub>Al<sub>12</sub>O<sub>48</sub>·2.5I<sub>2</sub> and Co<sub>3.5</sub>Na<sub>5</sub>Si<sub>12</sub>Al<sub>12</sub>O<sub>48</sub>·5.0I<sub>2</sub>

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Two crystal structures of iodine sorption complexes of dehydrated partially Co(II)-exchanged zeolite A,  $Co_{3.5}Na_5-A\cdot xI_2$ , x=2.5 and 5.0, have been determined by single crystal X-ray diffraction techniques. Both structures were solved and refined in cubic space group, Pm3m at  $21(1)^{\circ}C$ . The structures of  $Co_{3.5}Na_5-A\cdot 2.5I_2$  ( $a=12.173(1)^{\circ}A$ ) and  $Co_{3.5}Na_5-A\cdot 5.0I_2$  ( $a=12.130(1)^{\circ}A$ ) were refined to the final error indices,  $R_1=0.081$  and  $R_2=0.077$  with 261 reflections and  $R_1=0.103$  and  $R_2=0.112$  with 225 reflections, respectively, for which  $I>3\sigma(I)$ . In both structures, 3.5  $Co^{2+}$  ions and 4.5  $Na^{+}$  ions per unit cell lie at two crystallographically different 6-ring positions. 0.5  $Na^{+}$  ion lines in an 8-oxygen ring plance. Dehydrated  $Co_{3.5}Na_5-A$  sorbs 2.5 iodine molecules per unit cell at 70 °C (vapor pressure of  $I_2$  is ca. 8.3 torr) within 30 minutes and 5 iodine molecules per unit cell at 80 °C (vapor pressure of  $I_2$  is ca. 14.3 torr) within 24 hours. Each iodine molecule makes a close approach, along its axis to framework oxygen atom with  $I-I-O=175^{\circ}$ .

#### Introduction

The crystal structures of a bromine complex in synthetic zeolite  $4A^1$  and a similar iodine complex in zeolite  $5A^2$  have been reported. In each of these sorption complexes, it was found that approximately six dihalogen molecules were sorbed per unit cell; 6 bromine molecules in  $Na_{12}$ – $A^1$  and 5.65 iodine molecules in  $Ca_4Na_4$ – $A^2$ . The bromine molecules did not interact with the anionic framework or with the  $Na^+$  ions<sup>1</sup>.  $I_2$  molecules, however, were involved in charge-transfer complexes with the framework 8-ring oxygens<sup>2</sup>. No iodine– $Ca^{2+}$  or iodine– $Na^+$  interaction was observed  $I_2$ .

Several structures of  $\text{Cl}_2$  and  $\text{Br}_2$  sorption complexes of  $\text{Ag}^+$ , Eu(II), and Co(II)-exchanged zeolite A have been determined  $^{3\text{-}5}$ . In the structure of a chlorine sorption complex of vacuum–dehydrated Eu(II)–exchanged zeolite A, chlorine gas is reported to have oxidized Eu(II) to Ei(IV)^4. Chlorine gas has also oxidized hexasilver to AgCl as observed in the structure of a chlorine sorption complex of dehydrated, fully  $\text{Ag}^+$ -exchanged zeolite  $\text{A}^3$ . Additional six molecules per unit

cell are sorbed, which form charge transfer complexes with frame work oxygens (O–Cl–Cl = 166(2)°). 6 bromine molecules are sorbed in the dehydrated  $Ag_{12}–A\,;\,3.6$   $B_2$  molecules interact to draw with 3.6 of the 8.0 6–ring  $Ag^+$  ions into largecavity and 2.4  $Br_2$  molecules form charge transfer complexes with framework oxide ions (O–Br–Br = 174(4)°).  $^6$  When  $Cl_2$  gas was sorbed onto a single–crystal of vacuum–dehydrated  $Co_4Na_4–A,$  the chlorine molecules were coordinated to the Co(II) ion in a bent manner. The chlorine molecule is equatorially basic with respect to the hard acid Co(II) and the dichlorine bond is lengthened by a large amount, approximately 0.5 Å, upon complexation<sup>5</sup>.

This work was undertaken to further investigate the sorption properties of zeolite A and to determine the positions of the sorbed iodine molecules.

# **Experimental Section**

Single crystals of the synthetic molecular sieve sodium zeolite 4A, Na<sub>12</sub>Si<sub>12</sub>Al<sub>12</sub>O<sub>48</sub>·27H<sub>2</sub>O, were prepared by a modi-